



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

K-1968

Applicant : Yasumi Sago et al
Title : PLAXMA-ENHANCED PROCESSING APPARATUS
Serial No. : 09/809,274
Filed : March 16, 2001
Group Art Unit : 1763
Examiner : Luz L. Alejandro

Hon. Commissioner of Patents and Trademarks
Washington, D. C. 20231

7
7/14
MW
RECEIVED
JUL - 8 2002
TECHNOLOGY CENTER 1700

July 5, 2002

AMENDMENT

Sir:

In response to the restriction requirement of June 7, 2002, please
amend application as follows:

IN THE CLAIMS

Please amend claims 7 and 10, as follows:

Sub 20/ 7. (Twice amended) A plasma-enhanced processing apparatus as claimed
in claim 6, wherein;

C1 said front board is made of silicon poly-crystal or silicon
mono-crystal.

Sub 20/ 10. (Twice amended) A plasma-enhanced processing apparatus as claimed
in claim 6, wherein;

C2